

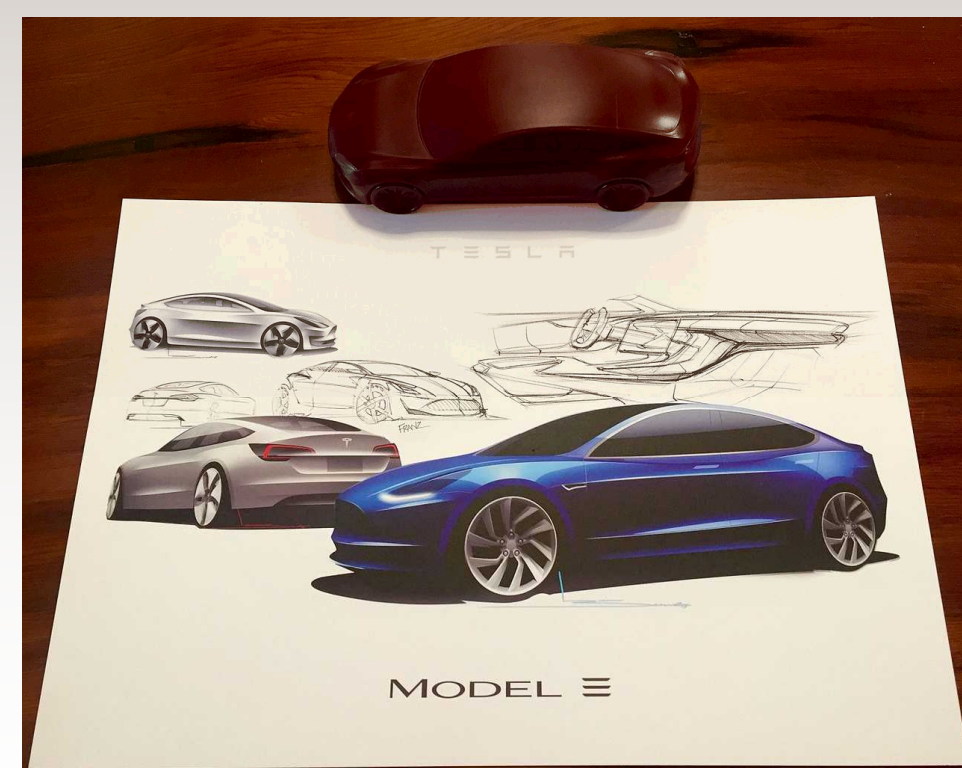
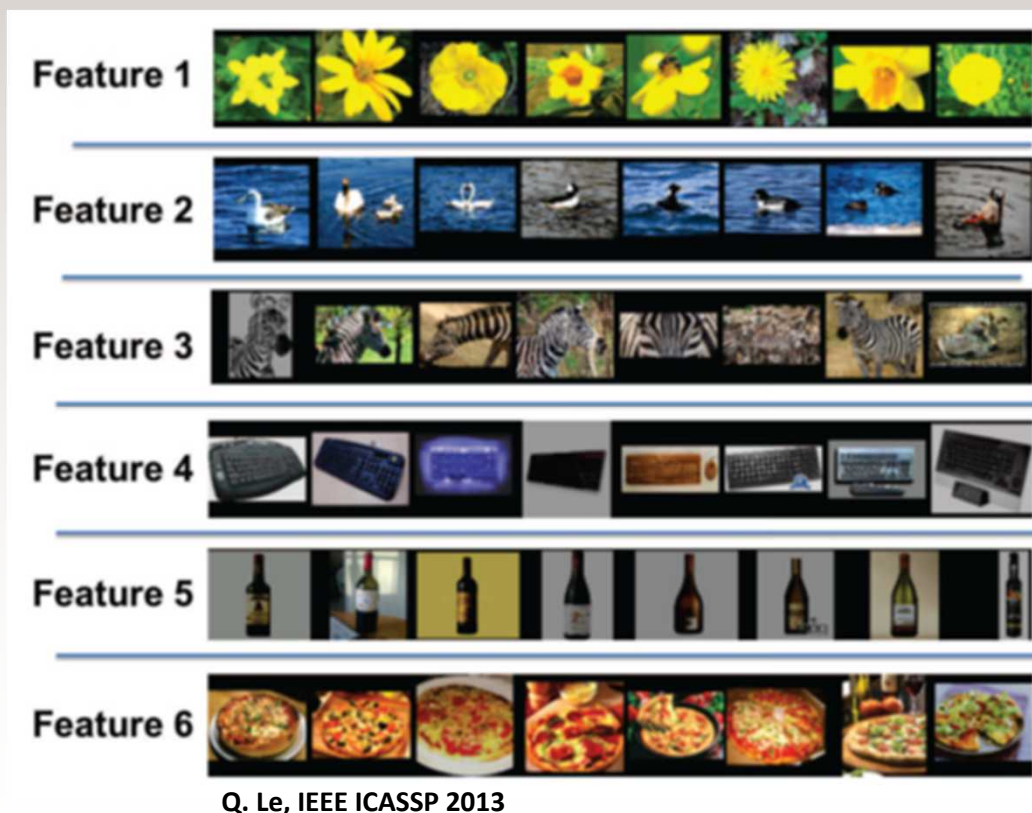
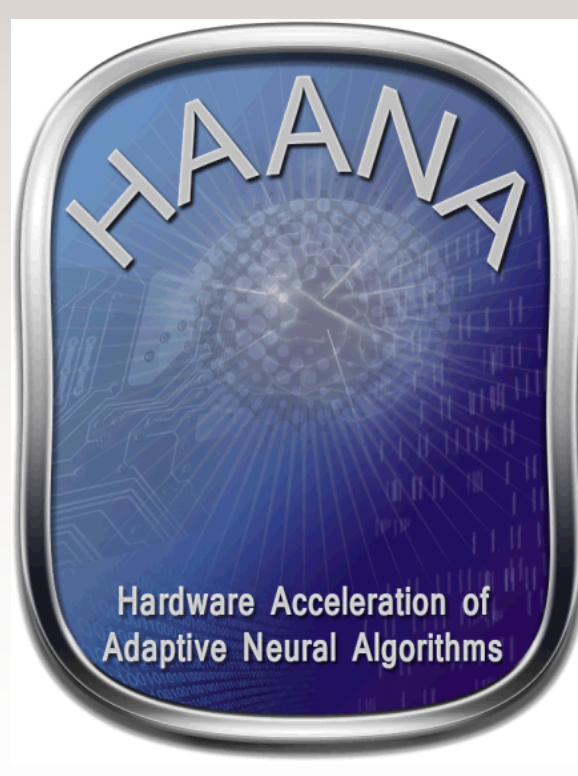
*Exceptional service in the national interest*



# Evaluating Resistive Memory Devices for Neuromorphic Computing Using Ultrashort Voltage Pulses

Jacobs-Gedrim, Robin<sup>1</sup>; Kotula, Paul; Goeke, Ronald; Mook, Bill; Finnegan, Patrick Sean; Smith, Carl Lee; Agarwal, Sapan; Gastian, Loren; Van Benthem, Mark; Jungjohann, Katie; Marinella, Matthew; James, Conrad D;

## Hardware Based Deep Learning



## Cybersecurity – Image Recognition – Self Driving Vehicles

Deep Learning provides solutions but currently requires a supercomputer and MWs of power... Hardware accelerator using analog devices may offer 10<sup>5</sup>-10<sup>6</sup> times power reduction – on a single chip!

## Matrix Vector Multiply

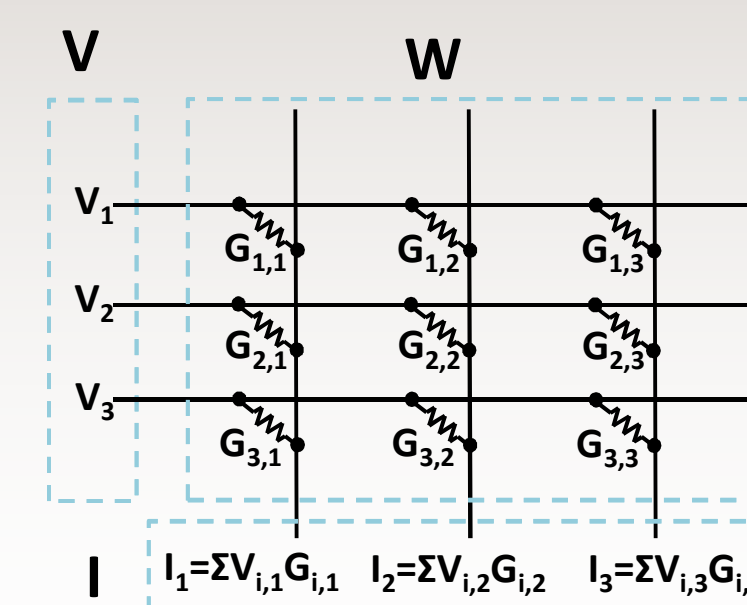
### Mathematical

$$V^T W = I$$

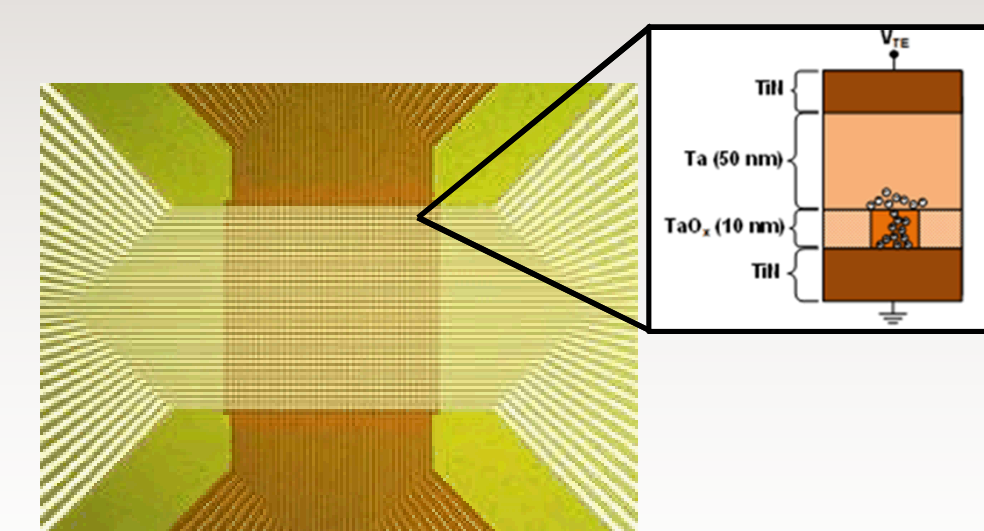
$$\begin{bmatrix} V_1 & V_2 & V_3 \end{bmatrix} \begin{bmatrix} W_{1,1} & W_{1,2} & W_{1,3} \\ W_{2,1} & W_{2,2} & W_{2,3} \\ W_{3,1} & W_{3,2} & W_{3,3} \end{bmatrix} = \begin{bmatrix} I_1 & I_2 & I_3 \end{bmatrix}$$

$$I_1 = \sum V_{i,1} W_{i,1} \quad I_2 = \sum V_{i,2} W_{i,2} \quad I_3 = \sum V_{i,3} W_{i,3}$$

### Electrical



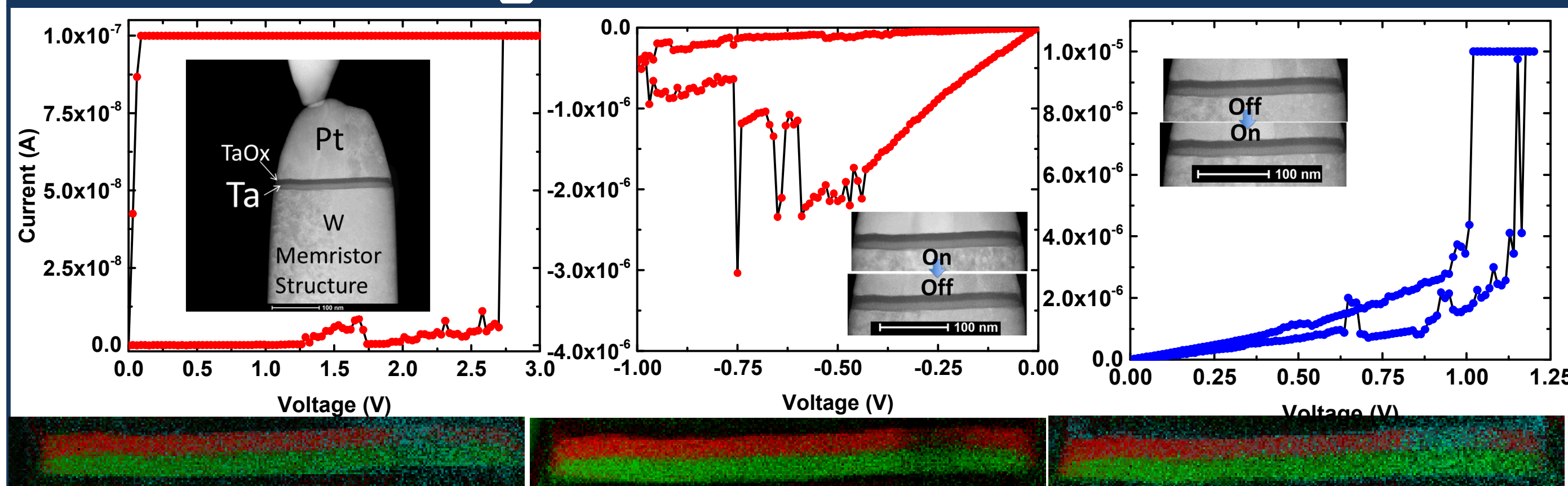
### Physical



- Matrix vector multiply is most computationally expensive process in deep learning
- Kirchhoff's laws allow for matrix vector multiply on crossbar of resistors
- Can implement programmable array of resistors using analog metal oxide resistive switching devices

*"Let physics do the computation"*

## Switching Mechanism: In-Situ TEM

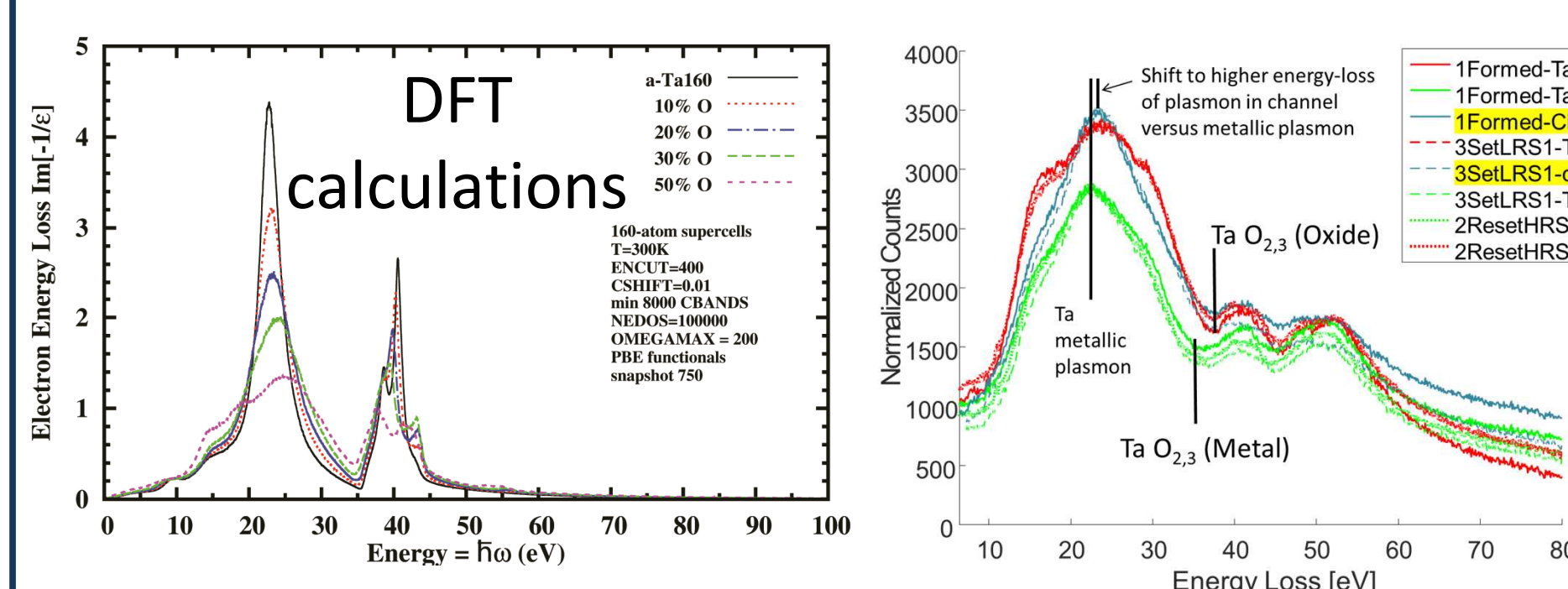


Forming -> LRS

Reset -> HRS

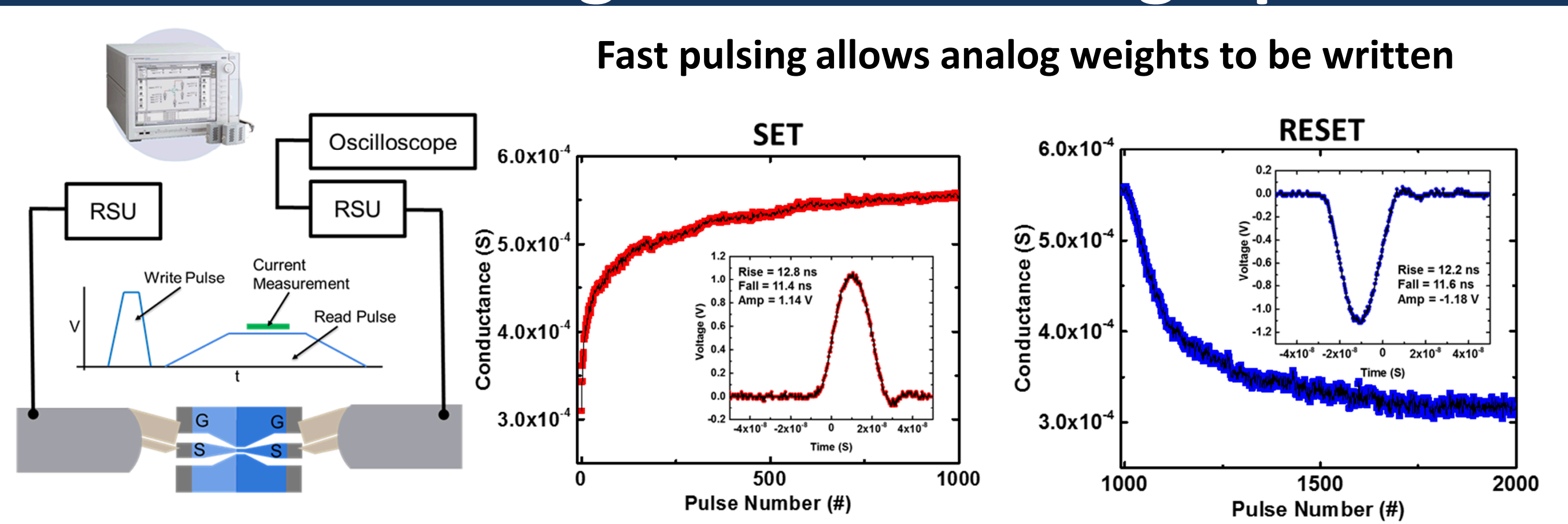
Set -> LRS

- Forming creates 50 nm filament (cyan).
- RESET changes the TaOx in the filament less metallic state (no cyan)
- SET returns the filament to conductive state (cyan)

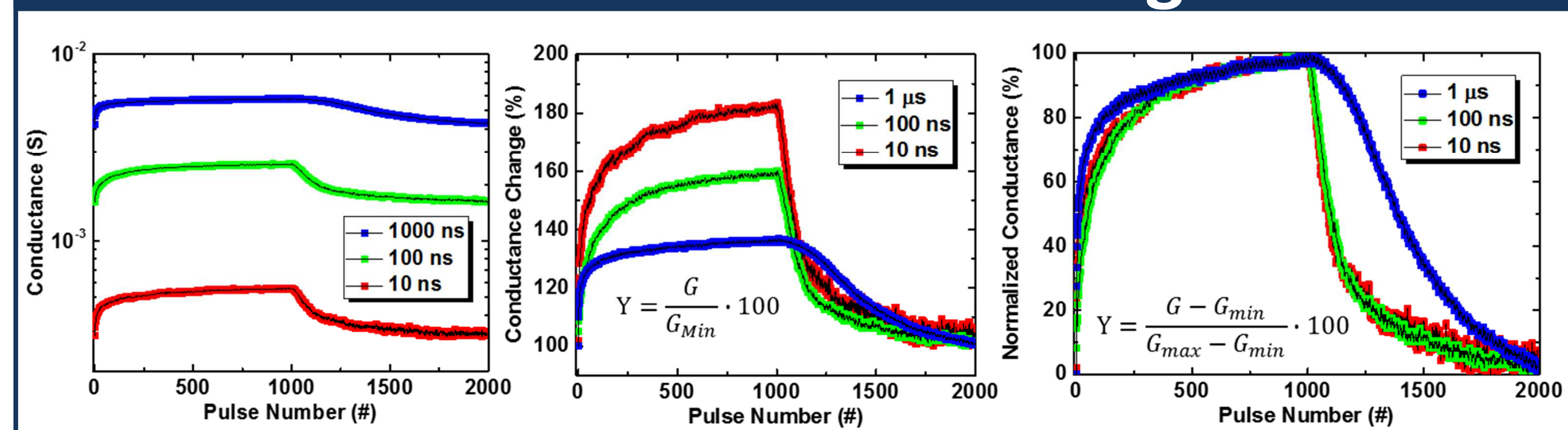


In filamentary region, Ta O<sub>2,3</sub> edge is consistent with oxidized Ta but there is a sharp metallic plasmon feature shifted to slightly higher energy loss consistent with DFT calculations for more metallic oxides

## Ultrashort Voltage Pulses: Analog Operation

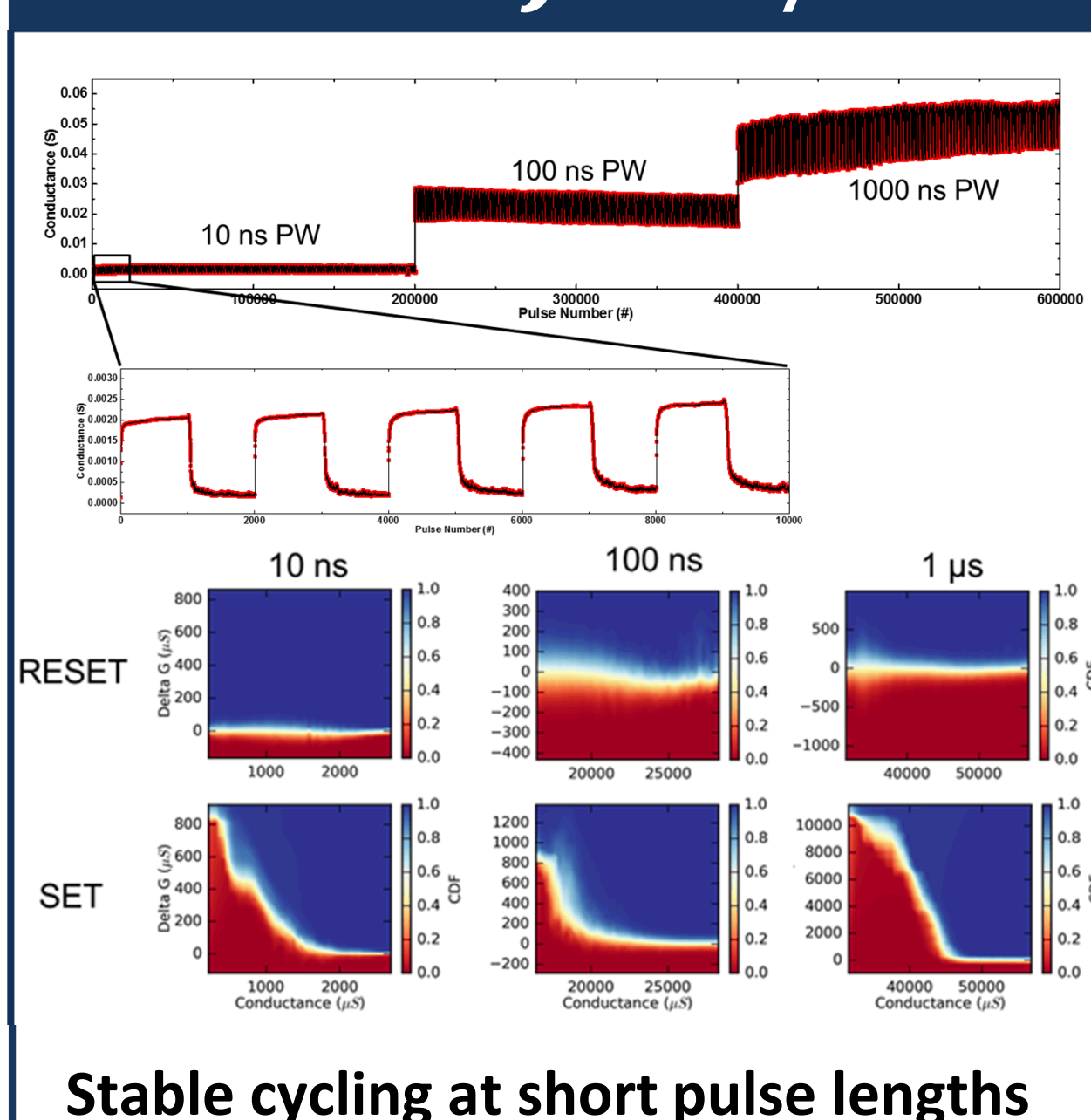


## Effect of Pulse Width and Edge Time



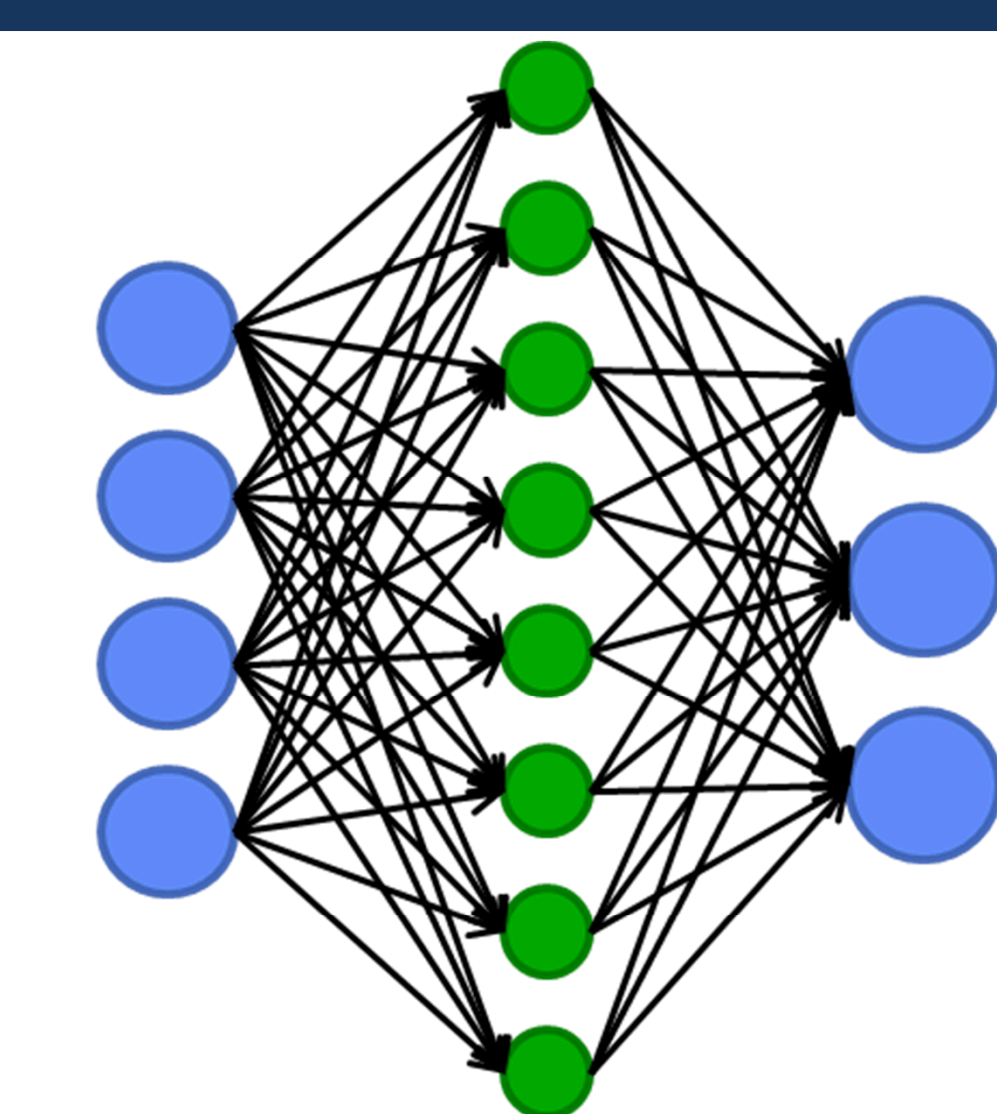
Fast pulsing reduces conductance range and increases relative conductance change

## CDF of ΔG/G



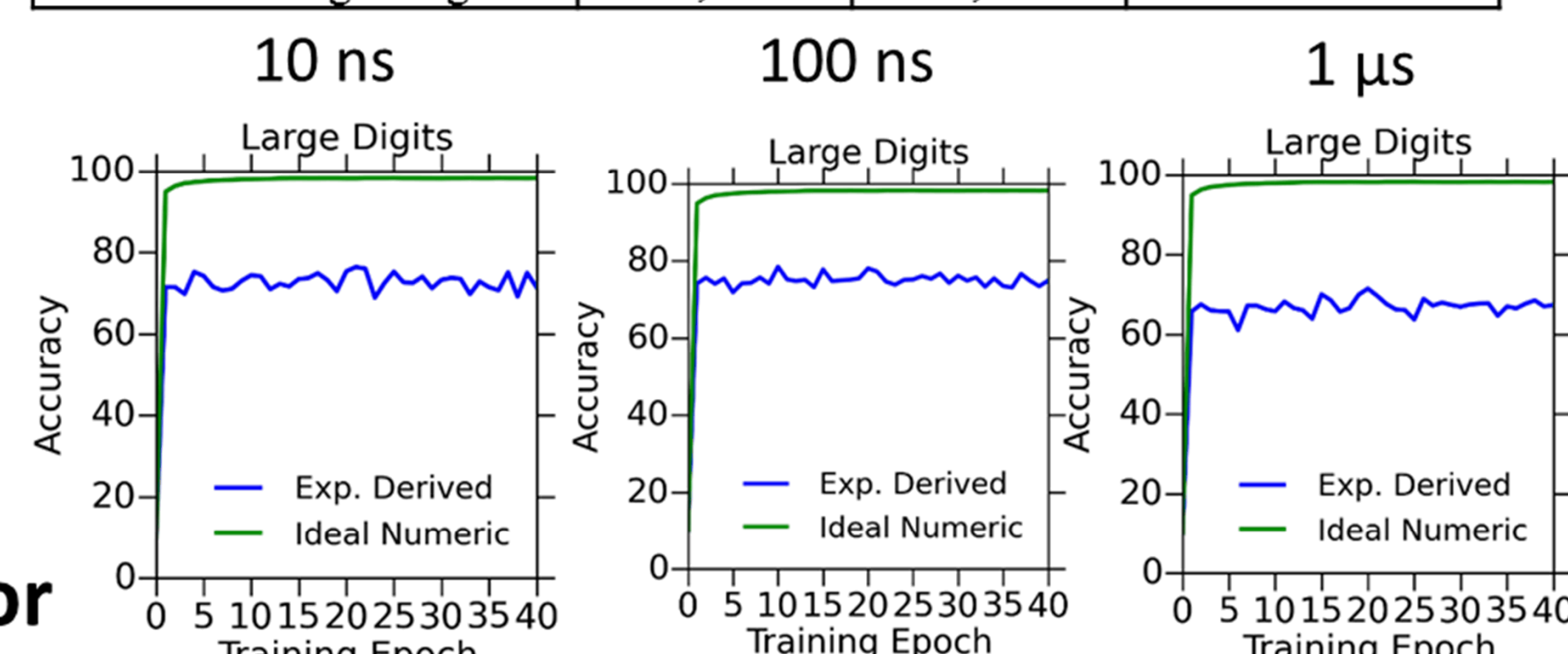
Stable cycling at short pulse lengths

## MNIST Data Set Training Results on CrossSim



Backpropagation of Error

Data set	# Training Examples	# Test Examples	Network Size
MNIST Large Digits	60,000	10,000	784x300x10



- Conductance switch in these TaOx devices is based on a metallic filamentary conduction mechanism
- Relative conductance change increased with shorter Pulse Width / Edge Time
- Ultrafast pulses may be employed to lower conductance switching range without reducing overall conductance change  
Ultrafast pulses down to 100s of ps are possible to implement in-silico!
- Major progress has been made toward "fab friendly" devices suitable for image recognition, but still a long way to go before achieving numerical equivalent